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Contents

v Conference Committee

LASER DAMAGE OF OPTICAL MATERIALS

12982 02 Universal strategies for enhancing the laser energy loading capability of pulse compression gratings [12982-36] 12982 03 Laser damage characteristics and nanosecond laser conditioning of multilayer dielectric gratings for picosecond-petawatt laser systems [12982-40] 12982 04 Laser cleaning of large-aperture optics used in high power laser facility with airflow assistance [12982-19] 12982 05 Influence of surface roughness on interfacial adsorption and laser ablation mechanisms of organic contaminants on fused silica [12982-5] 12982 06 Multi-physics coupling modeling for femtosecond laser damage in fused silica [12982-27] 12982 07 Transient numerical simulation of the effect of dielectric particle contaminant on fused silica in high-power laser system [12982-34] 12982 08 Effect of organic pollution on surface quality and laser damage in fused silica [12982-8] 12982 09 Non-conjugate multi-peak hot-images induced by double defects in high power laser systems [12982-29] 12982 OA Investigation on the dynamic damage process of HfO₂/SiO₂ anti-reflection coatings under 1064nm nanosecond laser irradiation [12982-12] 12982 OB Improved the laser-induced damage threshold of fused silica by atmospheric pressure plasma processing [12982-30] 12982 OC Elucidating the surface damage behavior of sol-gel silica anti-reflective films during lowpressure plasma cleaning [12982-4] 12982 0D Effect of metal grids configuration on photothermal properties of infrared optical windows [12982-35] 12982 OF Investigation on environmental adaptation of polyimide film in space applications [12982-18] 12982 OF Study on the characteristics of plasma generation from transparent optical elements induced **by pulse laser** [12982-10] 12982 0G Water dissolution ultra-precision continuous polishing of potassium dideuterium phosphate (DKDP) crystal [12982-25]

12982 OH	Research on the diffraction characteristics of reflecting volume Bragg gratings with different apodizing functions [12982-21]
12982 01	Preparation of enhanced AI/MgF ₂ vacuum ultraviolet reflective coatings using electron-beam evaporation [12982-20]
12982 OJ	Resistance comparison of 45° incident angle NIR laser anti-reflection film coating with different materials [12982-17]
12982 OK	The light modulation of Hertzian microcracks on optical glass with thin film [12982-7]
12982 OL	Simulation of display thermal deformation and error analysis in high precision reverse Hartmann test [12982-9]
12982 OM	Thickness dependence of VO ₂ microstructure and phase transition properties deposited on ITO substrate [12982-33]
12982 ON	Correction of thickness uniformity of meter-scale Ag film [12982-31]
12982 00	Effects of multiple contaminant components on spectral performance of reflective mirrors in resonance ionization spectroscopy [12982-26]
12982 OP	Simulation study on laser damage threshold of optical window materials [12982-11]
12982 OQ	Extrapolation method for performance evolution of thin film materials under the synergistic effect of space radiation environments [12982-15]
12982 OR	Experimental investigation of laser induced breakdown thresholds for bulk water [12982-28]
12982 OS	Synergistic effect of space radiation environments on the mechanical properties of polyimide films [12982-16]
12982 OT	Nodular defects induced laser damage of 532 nm thin-film polarizers [12982-13]
12982 OU	Influence of absorption distribution in Mo/Si multilayers on 13.5 nm femtosecond laser damage morphologies [12982-14]
12982 OV	Control of the metallographic and mechanical properties of Cr8 cold-work die steel by laser continuous/dispersed quenching [12982-1]
12982 OW	Progress on defect inspection for large-aperture optics [12982-32]
	ADVANCED OPTICAL MATERIALS
12982 OX	Yb ³⁺ /Tm ³⁺ co-doped germanate-tellurite glass: conversion luminescent and temperature- sensing characteristics [12982-6]

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